

Supporting Information

Amorphous Tin-based Nanohybrid for Ultra-Stable Sodium Storage

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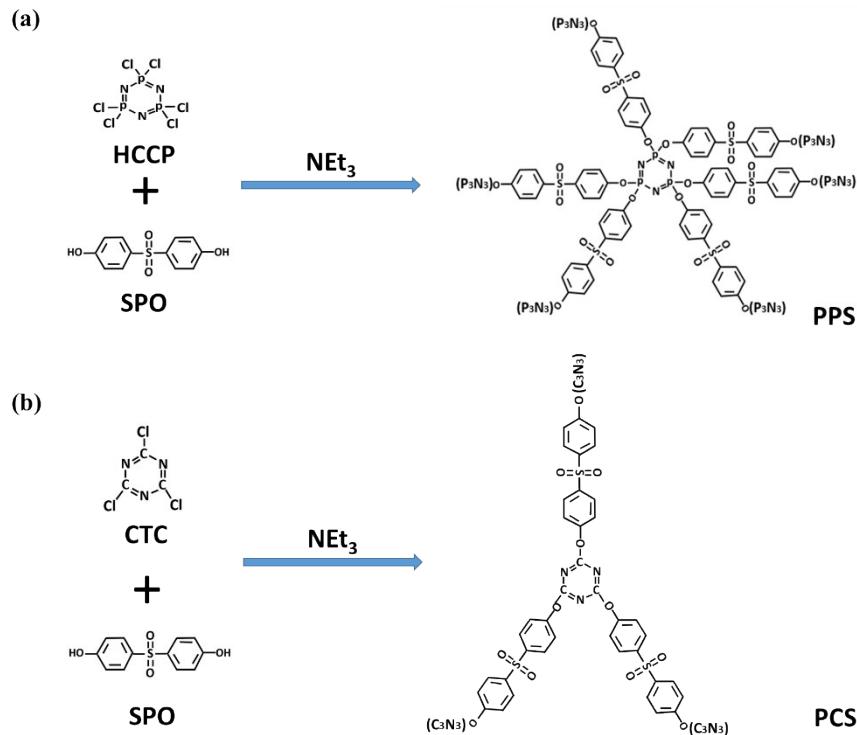


Fig. S1 a) A polymerization of hexachlorocyclophosphazene and 4, 4'-sulfonyldiphenol to obtain a supermolecule polymer of poly(cyclotriphosphazene-co-4,4'-sulfonyldiphenol) (PPS). b) A polymerization of cyanuric chloride and 4, 4'-sulfonyldiphenol to obtain a supermolecule polymer of poly(cyanuric-co-4,4'-sulfonyldiphenol) (PCS).

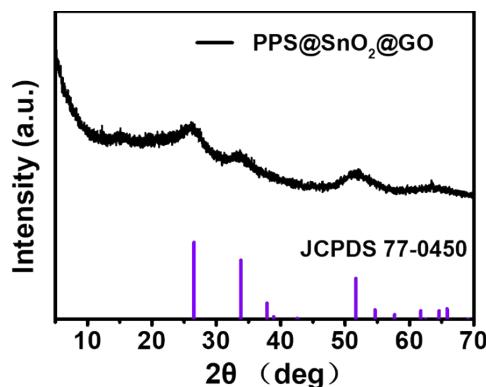


Fig. S2 a) XRD patterns of PPS@SnO₂@GO.

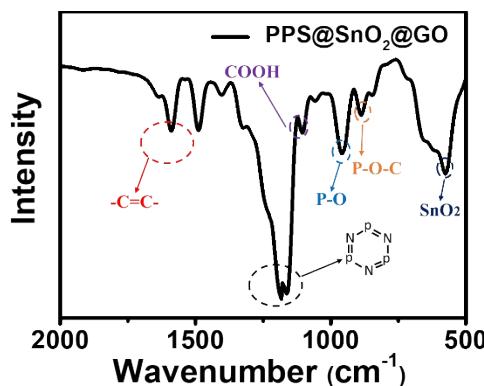


Fig. S3 FT-IR spectra of PPS@SnO₂@GO.

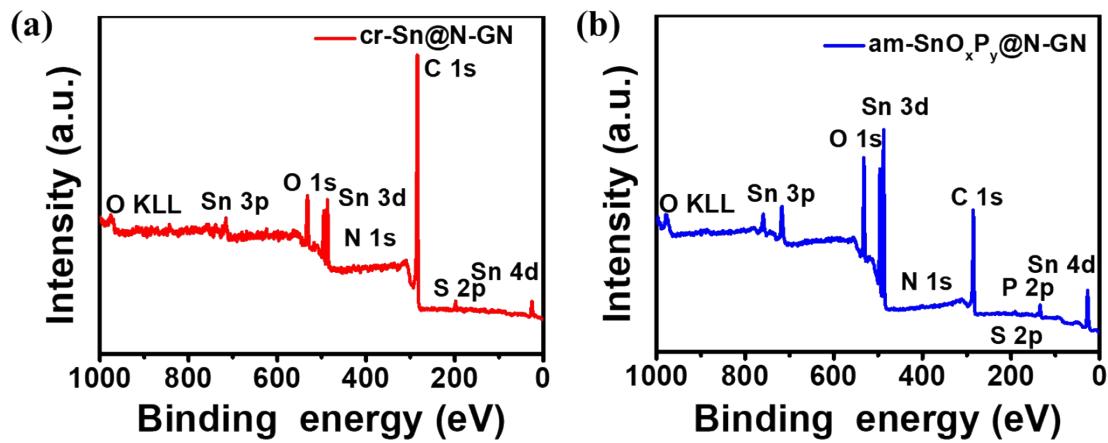


Fig. S4 a) XPS survey spectrum of am-SnO_xP_y@N-GN. b) XPS survey spectrum of cr-Sn@N-GN.

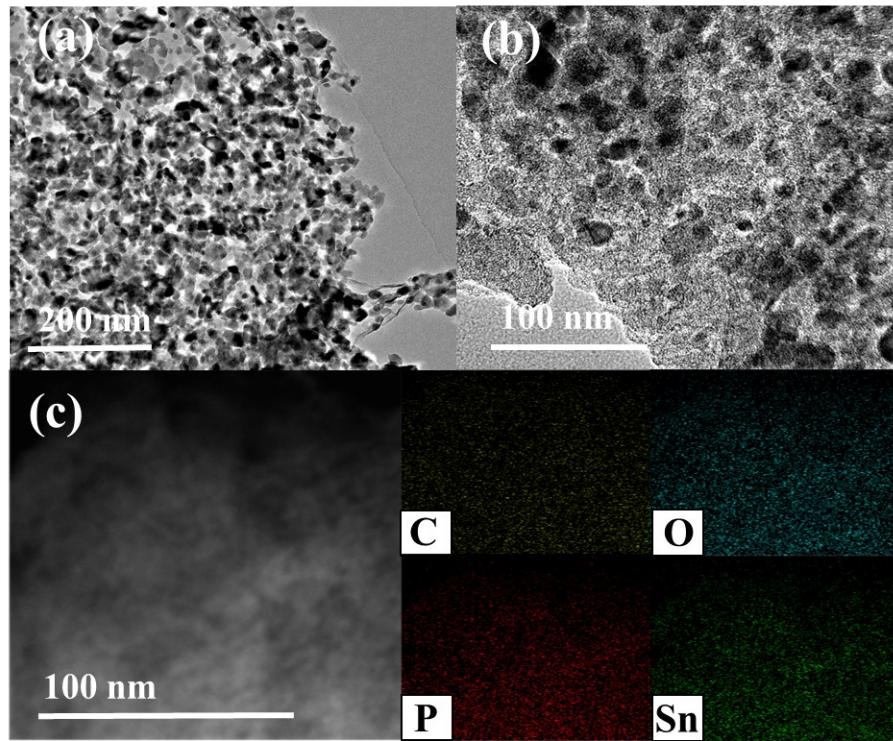


Fig. S5 a) TEM images of cr-Sn@GN architecture. b) TEM images of PPS@SnO₂@GO architecture. b) EDS mapping image of am-SnO_xP_y@N-GN (up-left: C-K mapping, up right: O-K mapping, bottom-left: P-K mapping, bottom-right: Sn-K mapping).

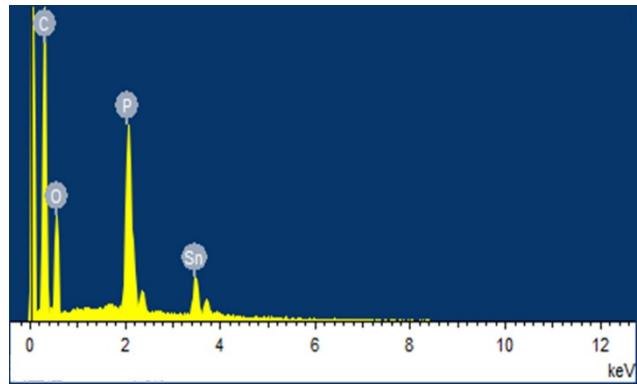


Fig. S6 EDS spectra elemental analysis of am-SnO_xP_y@N-GN.

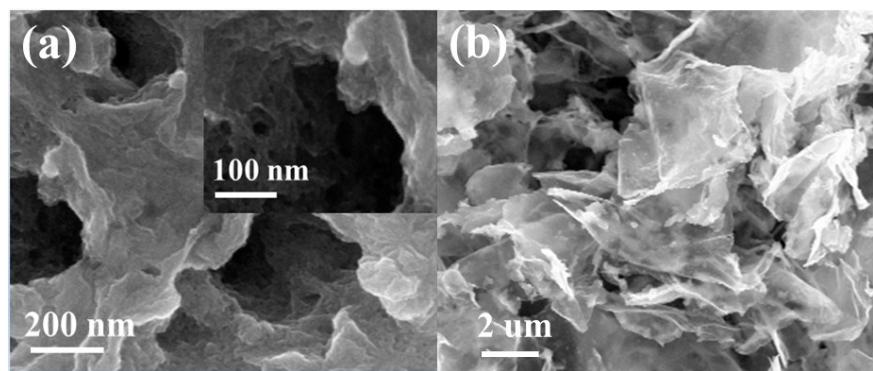


Fig. S7 a) SEM images of am-SnO_xP_y@N-GN architecture. b) SEM images of cr-Sn@GN architecture.

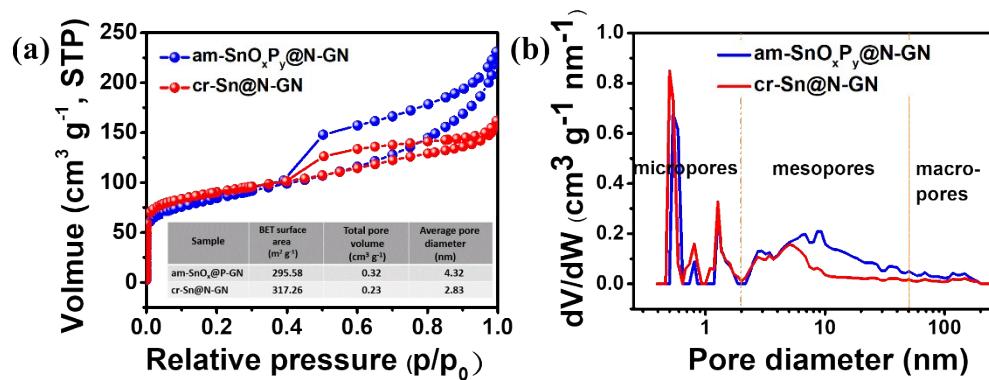


Fig. S8 a) N₂ adsorption/desorption isotherm of am-SnO_xP_y@N-GN and cr-Sn@N-GN architecture. b) The corresponding pore distribution curves (BJH method).

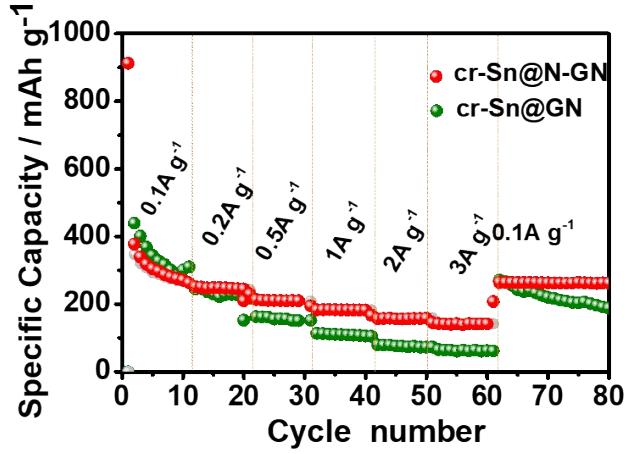


Fig. S9 Rate capabilities of cr-Sn@N-GN and cr-Sn@GN.

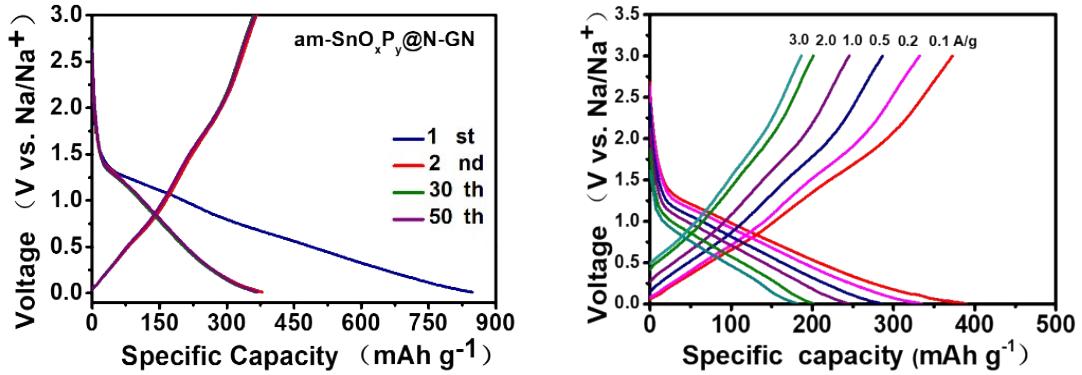


Fig. S10 a) Galvanostatic discharge-charge profiles of the am-SnO_xP_y@N-GN at 100 mA g⁻¹. b) Galvanostatic discharge-charge profiles of the am-SnO_xP_y@N-GN from 100 mA g⁻¹ to 3000 mA g⁻¹.

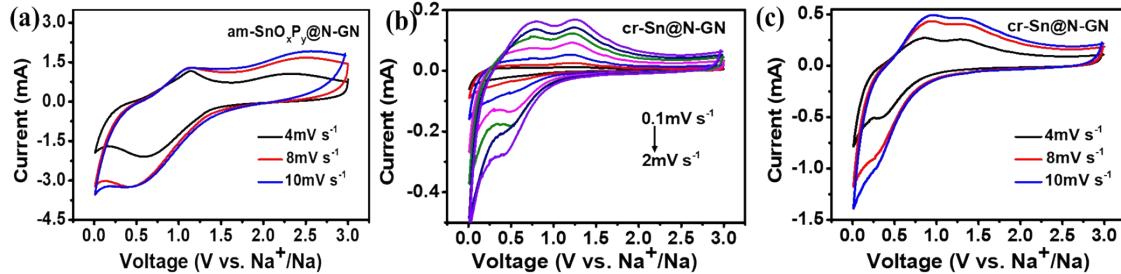


Fig. S11 a) CV curves of am-SnO_xP_y@N-GN at various sweep rates from 4 to 10 mV s⁻¹. b) CV curves of cr-Sn@N-GN at various sweep rates from 0.1 to 2 mV s⁻¹. b) CV curves of cr-Sn@N-GN at various sweep rates from 4 to 10 mV s⁻¹.

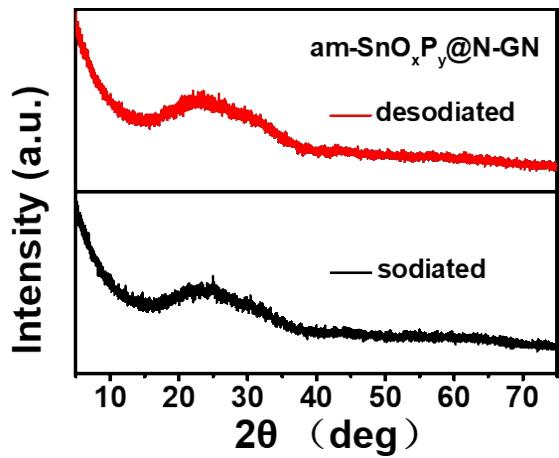


Figure. S12 XRD spectra of the am-SnO_xP_y@N-GN electrode at different stages.

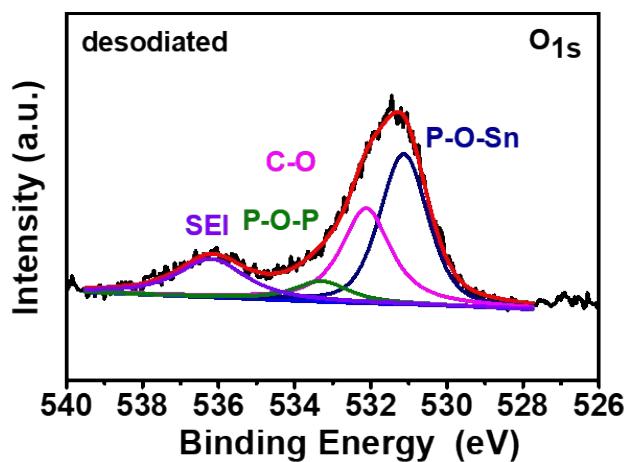


Fig. S13 Chemical composition analysis though XPS of O for am-SnO_xP_y@N-GN.

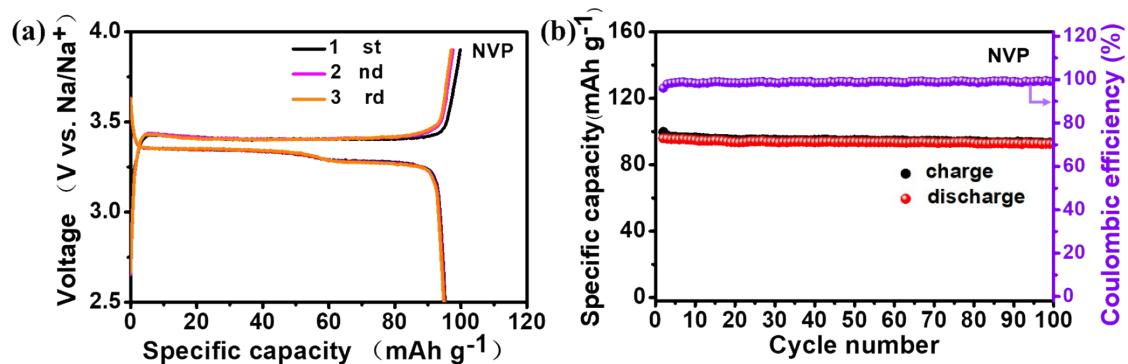


Fig. S14 a, b) Electrochemical performance of Na₃V₂(PO₄)₃/C (NVP) cathode. a) charge/discharge curves of the NVP cathode at 1C (1C = 118 mA h g⁻¹). b) cycling performance of the Na₃V₂(PO₄)₃/C (NVP) cathode at 1C.

Table S1 ICP-OES and EDS spectra elemental analysis

	Sn	P	O
ICP (wt%)	45	n/a	n/a
EDS (wt%)	18.4	12.2	18.8
EDS (at%)	1	2.4	7.5

Table S2. The Comparison of the Electrochemical Properties for the am-SnO_xP_y@N-GN and Other Works in Coin Cell Configuration.

Sample	Cycling stability			Rate capacity			Re	
	Current density [mA g ⁻¹]	Capacity after cycles [mAh g ⁻¹]	C.N (capacity retention(%))	Current density [mA g ⁻¹]				
				(Capacity [mAh g ⁻¹])				
am-SnO _x P _y @N-GN	1000	201.6	3000(74.4%)	100(378)	1000(267)	6000(78)	<input checked="" type="checkbox"/>	
Yolk-Shell Sn@C	1000	200	1000(40.0%)	200(450)	1000(320)	5000(200)	1	
Mesoporous SnO ₂	180	200	500(21.0%)	120(800)	660(560)	1320(450)	2	
SnO ₂ /CNT-SCO ₂	50	230	100(83.3%)	20(500)	500(280)	1000(220)	3	
Sn/SnO ₂ /C	100	300	100(66.6%)	100(282)	500(280)	1000(120)	4	
SnO ₂ -PC	100	281	250(98.1%)	100(310)	1600(107)	3200(80)	5	
SnO ₂ /GO	113	245	150(55.8%)	50(480)	500(196)	1000(125)	6	
Sn ₂ Nb ₂ O ₇ /SnO ₂	100	300	100(81.1%)	100(302)	1000(202)	5000(135)	7	
SnO ₂ /3D-RGO	50	223	350(53.6%)	80(321)	800(276)	1200(266)	8	
cactus-like SnO ₂	50	500	50(65.5%)	180(312)	540(276)	3200(130)	9	

Cycle number denoted as C.N. Represents our work. Capacity retention calculated from the first charge capacity

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